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Multiwavelength, Sub-Nanosecond Yb:YAG/Cr⁴⁺:YAG/YVO₄ Passively Q-Switched Raman Microchip Laser

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Abstract—We have demonstrated a multiwavelength, subnanosecond Yb:YAG/Cr⁴⁺:YAG/YVO₄ passively Q-switched Raman microchip laser (PQSRML) emitting at 1–1.26 μ m. Multiple wavelength Stokes laser radiations at 1123, 1134, 1260 nm and 1079, 1134, 1157, 1260 nm have been obtained at different pump power levels, respectively. The second-order Stokes laser at 1.26 μ m increases rapidly with the pump power and becomes the dominant component in the laser emitting spectrum. The maximum average output powerof 135.4 mW is achieved at the absorbed pump power of 2.64 W, meanwhile, the pulse duration is 440 ps, and the peak power is 9.2 kW for the Raman laser. The repetition rate of 20.3 kHz has been achieved. The multi-wavelength, sub-nanosecond lasers at 1–1.26 μ m with adjustable frequency separation depending on pump power have potential applications in terahertz wave generation, photodynamic therapy, and generating red laser.

Index Terms—Laser-diode pumped, microchip lasers, passively Q-switched, Raman lasers, Yb:YAG.

I. INTRODUCTION

C OMPACT pulsed lasers with simultaneous dual- or multiwavelength oscillation possess significant practical applications in disease treatment [1], optical sensing [2], holographic interferometry [3], differential absorption laser lidar (DIAL) [4], optical communication [5], and generating terahertz (THz) wave radiation with difference-frequency generation (DFG) method [6]. The pulsed dual- or multi-wavelength solid-state lasers have been obtained by using multiple fluorescent emission lines of Nd³⁺ doped laser materials [7]–[10]. However, extra optical elements such as frequency selector, etalon or specially designed coatings are needed to balance the gain and loss for the individual emission peak line, which makes the laser complicated and high cost. Recently, pulsed dual-wavelength laser has been produced in a resonator with two different laser gain media

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[11]. The optical parametric oscillator (OPO) is a traditional method for generating multi-wavelength oscillation [12], however, the strict phase matching required in the OPO system introduces instabilities owing to the temperature rising of nonlinear crystals or the misalignment of cavity. Pulsed multi-wavelength lasers have been synchronized with stimulated Raman scattering (SRS) effect and become a hotspot for developing compact multi-wavelength lasers with high peak power. The advantages such as free of phase-matching condition, clean-up effect and cascaded characteristics of SRS make Raman laser an efficient and flexible method to generate new laser radiations, which are difficultly obtained by direct lasing from conventional rareearth doped laser media. For example, there is a lack of laser gain material with high gain property at 1.1–1.3 μ m. It has been demonstrated that the lasers oscillating at 1100-1150 nm are ideal pump sources for directly pumping Ho³⁺-doped fiber lasers without sensitizers [13] and generating yellow laser by frequency doubling [14]. The laser around 1.26 μ m can be used as the laser source to excite oxygen directly in drug-free photodynamic therapy (PDT) for the treatment of some oncological diseases [15], [16]. Moreover, the solid-state red lasers at 630 nm by frequency doubling of 1.26 μ m have been identified as simple and robust laser sources replacing the conventional dye red lasers pumped by huge argon or metal vapor lasers for the treatment of nonmelanoma skin cancers (NMSCs) [17], [18]. Therefore, the development of the multi-wavelength Raman lasers at 1–1.3 μ m based on the SRS nonlinear process is of great scientific and practical value.

Among various Raman crystals, YVO₄ crystal has been proven to be an excellent Raman crystal with good optical and mechanical properties such as large Raman gain coefficient, high laser damage threshold and a relative broad spectral transparency region. YVO₄ crystals doped with Nd³⁺ or Yb³⁺ ions are also great candidates for self-Raman lasers to reduce the intracavity loss [19]. Moreover, YVO₄ crystal possesses multiple Raman frequency shift lines for generating multi-wavelength Raman laser with small frequency separation. Acoustic-optic (AO) Q-switched, dual- or multi-wavelength intracavity Raman lasers using conventional Nd³⁺ doped laser materials and YVO₄ Raman crystals operating at 1174 nm/1175 nm [20], 1178.9 nm/1199.9 nm [21], 1522 nm/1524 nm [22], and 1.2–1.3 μ m [23] have been reported. However, long cavity and active Q-switch make the laser system complex and unsuitable for generating short pulse duration. A miniature, economic,

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multi-wavelength laser with sub-nanosecond pulse duration and high peak power is extremely needed for many applications such as ranging and imaging with high resolution [24], [25], microfabrication, nonlinear frequency conversion, and remote sensing [26], [27]. Passively Q-switched microchip lasers (PQSMLs) have been widely used to generate sub-nanosecond or picosecond pulses due to the extremely short cavity [28], [29]. And PQSMLs are relatively stable, insensitive to misalignment, and suitable for commercially fabricated [28], [30]. Therefore, combining SRS conversion process with LD pumped PQSML is a reasonable solution for developing high peak power, subnanosecond pulse duration, multi-wavelength lasers. A subnanosecond, Cr⁴⁺: YAG passively Q-switched Raman microchip laser (PQSRML) using Nd:LSB or Nd:YAG laser crystal and Ba(NO₃)₂ Raman crystal was firstly reported in 2003 [31], which provides a new method for generating short pulses with multiple laser emission.

Compared with Nd³⁺ doped laser crystals, ytterbium (Yb) ions doped laser gain media are more suitable for developing miniature multi-wavelength microchip lasers with high peak power because of their excellent properties such as broad spontaneous emission spectra, simple energy level structure, long fluorescence lifetime, high doping concentration and low thermal loading [32]. PQSMLs with sub-nanosecond pulse duration using Yb: YAG [33] and Yb: KLu(WO₄)₂ [34] as laser gain media emitting at 1 μ m have been demonstrated. Yb³⁺:KGd(WO₄)₂ [35], [36], Yb³⁺:KY(WO₄)₂ [37], Yb:KLu(WO₄)₂ [38], [39] and Yb³⁺:YVO₄ [40] crystals have been used to generate firstorder Stokes laser at 1.1 μ m in Cr⁴⁺:YAG passively Q-switched lasers. The performance of self-Raman lasers are restricted by the severe thermal loading induced by the simultaneously fundamental laser and Stokes laser oscillating in one crystal. Moreover, the tradeoff between the fundament laser and Raman laser oscillation in self-Raman gain medium makes the self-Raman laser difficult to be optimized and the output laser wavelengths difficult to control. In 2015, an AO Qswitched intracavity Yb:YAG/YVO4 Raman laser emitting at 1157.6 nm was firstly reported [41]. Recently, a passively Qswitched Raman laser emitting at 1092.6 nm-1290.1 nm using Yb:YAG/YAG/Cr⁴⁺:YAG/YAG composite crystal and YVO₄ Raman crystal has been experimentally demonstrated [42]. Composite laser materials are ideal for developing miniature passively Q-switched Raman laser when the doping concentration and thickness of different optical materials are optimized. Therefore, more efforts are extremely needed for developing high peak power, multi-wavelength PQSRMLs with separated laser medium and Raman medium.

In this paper, simultaneous multiple wavelength Raman lines emitting at 1–1.26 μ m have been generated from a LD endpumped PQSRML with a Yb:YAG crystal as gain medium and a YVO₄ crystal as Raman medium. Sub-nanosecond, multiwavelength laser has been obtained with Raman frequency shift lines of 890 cm⁻¹, 816 cm⁻¹, and 259 cm⁻¹ as well as cascaded SRS process of YVO₄ crystal originated from 1030 and 1050 nm fundamental lasers. The pump power dependent Raman laser emitting spectra have been investigated based on the competition among different Raman vibrational modes



Fig. 1. Schematic diagram for a 940 nm laser-diode end-pumped Yb:YAG/ Cr^{4+} :YAG/YVO₄ PQSRML.

and different fundamental laser wavelengths. Four Stokes laser lines have been simultaneously obtained as the absorbed pump power (P_{abs}) exceeds 2.17 W. The average output power of 135.4 mW and repetition rate of 20.3 kHz have been achieved at $P_{abs} = 2.64$ W. The Raman laser with pulse duration of 440 ps and the peak power of 9.2 kW has been obtained in the Yb:YAG/Cr⁴⁺:YAG/YVO₄ PQSRML.

II. EXPERIMENTAL ARRANGEMENT

The experimental configuration of the LD end-pumped Yb:YAG/Cr⁴⁺:YAG/YVO₄ PQSRML for generating multiwavelength laser radiation is shown in Fig. 1. A continuouswave, fiber-coupled 940 nm LD arrays with a fiber core size of 200 μ m and numerical aperture (N.A.) of 0.22 was served as the pump source. The optical coupling system was a combination of two aspheric lenses with 8 mm focal length. The incident pump beam was re-imaged inside the Yb: YAG crystal with a focused spot diameter of about 100 μ m. A 1.2-mm-thick, 10 at.% doped Yb:YAG crystal and a 2-mm thick, c-cut YVO₄ crystal were selected as the laser gain crystal and Raman conversion crystal, respectively. The rear mirror of the microchip laser was formed by directly coating in the rear surface of the Yb:YAG crystal with anti-reflection (AR) at 940 nm and high-reflected (HR) at 1030 nm-1100 nm (R > 99.8%). The intracavity surfaces of the Yb:YAG and YVO4 crystals were AR coated at 1030 nm-1100 nm to decline the internal loss. The output coupler (OC) of the microchip laser was formed with one surface of YVO₄ crystal coated with T $\approx 1\%$ at 1030 nm, T < 0.5% at 1040–1140 nm, T \approx 1.5% at 1156 nm and T \approx 29% at 1260 nm, respectively. A 0.5-mm-thick Cr⁴⁺:YAG crystal with an initial transmission of 95% for 1030 nm was served as a Q-switch, and both surfaces of the Cr⁴⁺:YAG crystal were AR coated for minimizing the Fresnel loss. The Cr⁴⁺:YAG sample was tightly sandwiched between the Yb:YAG crystal and YVO₄ crystal. The optical elements (Yb:YAG, Cr⁴⁺:YAG, and YVO4 crystal) were mechanically put in contact with each other by two copper holders with 3 mm diameter central apertures, which also act as the heat sink to relieve the thermal accumulation. The overall length of the plane-parallel cavity is only 3.7 mm. The experiments were carried out at room temperature and no active cooler were applied. The average output power was measured by a Thorlabs PM200 power meter in the experiment. An Anritsu optical spectral analyzer (MS9740A) was employed to record the emitting laser spectra. A digital oscilloscope (6 GHz bandwidth, TDS6604, Tektronix Inc.) and a 5 GHz In-



Fig. 2. Evolution of the laser emitting spectra of Yb:YAG/Cr⁴⁺:YAG/YVO₄ PQSRML at different P_{abs} .

GaAs photo-diode were used to record and analysis the laser pulse characteristics.

III. EXPERIMENTAL RESULTS

The absorbed pump powers (Pabs) of the Yb:YAG crystal in the Yb:YAG/Cr4+:YAG/YVO4 PQSRML at different incident pump powers were obtained by measuring the pump power before incident on the Yb:YAG crystal and after passing through the Yb:YAG crystal. The absorption efficiency of the Yb:YAG crystal at different incident pump powers was around 62%. Fig. 2 depicts the evolution of the lasing spectra of the Yb:YAG/Cr⁴⁺:YAG/YVO₄ PQSRML at different P_{abs} . The wavelengths of the Stokes laser and the residual fundamental laser were shown in the laser emitting spectra. The Raman laser at 1134.24 nm is the first-order Stokes laser with the strongest Raman frequency shift of 890 cm⁻¹ converted from 1030 nm fundamental laser when Pabs reaches the Raman lasing threshold of approximately 0.93 W. With further increase in Pabs, the intensity of the first-order Stokes laser at 1134 nm increases continuously. When P_{abs} reaches 1.4 W, the intensity of the first-order Stokes laser is nearly the same as that of the 1030 nm fundamental laser. As Pabs was further increased to over 1.55 W, two new Raman laser radiations at 1123.04 nm and 1260.52 nm were generated, which were the first-order Stokes laser with the Raman shift of 816 cm⁻¹ and the second-order Stokes laser with the Raman shift of 890 cm⁻¹, respectively. The Raman laser simultaneously oscillated at 1123.04 nm, 1134.24 nm, and 1260.52 nm, while the fundamental laser still oscillated at 1030 nm at $P_{abs} = 1.77$ W. The second-order Stokes laser at 1260 nm is attributed to the sufficient intracavity intensity of the first-order Stokes laser at 1134 nm, which served as the pump source for the second-order Stokes laser. Multi-wavelength oscillation around 1030 nm, 1123 nm, 1134 nm, and 1260 nm is kept when P_{abs} is within the range between 1.55 W and 2.17 W. When Pabs is increased to 2.2 W, the first-order Stokes laser at 1123 nm disappears, while a new fundamental laser at 1050 nm and a new Raman laser at 1156.22 nm begin to oscillate. The new Raman laser at 1156 nm is the first-order Stokes laser with the Raman shift of 890 cm⁻¹ converted from the 1050 nm fun-



Fig. 3. Average output power of Yb:YAG/Cr⁴⁺:YAG/YVO₄ PQSRML versus P_{abs} . The average output powers of the Raman laser and residual fundamental laser are also plotted at different P_{abs} .

damental laser. The second-order Stokes laser increases rapidly and becomes the major component in the laser emitting spectrum when P_{abs} exceeds 1.86 W. When P_{abs} was further increased to 2.64 W, a weak first-order Stokes laser at 1079.22 nm converted from the 1050 nm fundamental laser with the Raman shift of 259 cm⁻¹ was observed. The intensities of the first-order Stokes lasers at 1134 nm and 1156 nm as well as the fundamental laser at 1030 nm and 1050 nm gradually decrease, and the intensity of the second-order Stokes laser at 1260 nm becomes stronger with P_{abs} when P_{abs} exceeds 2.17 W. The laser spectra at different absorbed pump powers show that fundamental laser, first-order Stokes laser and second-order Stokes laser shift to longer wavelength (red-shift) with the absorbed pump power. However, the relative intensities of multiple laser lines maintained stable over time when the pump power was set.

Fig. 3 shows the variation of the average output power of the Yb:YAG/Cr⁴⁺:YAG/YVO₄ PQSRML as a function of P_{abs}. A longpass filter was employed to split the Raman laser and fundamental laser. The measured average output powers of the fundamental laser and Raman laser at different Pabs are also shown in Fig. 3. The 1030 nm fundamental lasing threshold was about 0.74 W. The 1134 nm Raman laser started to oscillate when Pabs was increased to approximately 0.93 W. When the intracavity peak power intensity exceeds the SRS threshold, the simultaneous multiple Stokes lasers operation in the Yb:YAG/Cr⁴⁺:YAG/YVO₄ PQSRML is dominant, and has significant impact on the average output power. The total average output power does not increase linearly with Pabs. Based on the laser oscillating wavelength (as shown in Fig. 2), the variation of the output power with P_{abs} can be divided into four sections, as shown in Fig. 3. The total average output power of 1030 nm fundamental laser and 1134 nm Raman laser increases linearly with Pabs when Pabs is lower than 1.55 W. The slope efficiency is 4.7%. When P_{abs} is within the range between 1.55 W and 2.17 W, 1123 nm Raman laser and 1260 nm second-order Stokes laser together with 1030 nm fundamental laser and 1134 nm Raman laser oscillate simultaneously. The total average output power increases fast with Pabs, and the slope efficiency is increased



Fig. 4. Typical pulse trains of Yb:YAG/Cr⁴⁺:YAG/YVO₄ PQSRML at $P_{abs} = 2.2$ W and 2.64 W, respectively.

to 11%. When Pabs is higher than 2.17 W, the Raman laser converted from 1030 nm and 1050 nm dual-wavelength fundamental laser intensifies the competition among the Raman lasers. The total average output power increases linearly with Pabs, however, the slope efficiency is decreased to 6.4%. The decline of the slope efficiency at the high pump power was due to the strong gain competitions among different fundamental lasers as well as Raman lasers. And severe thermal loading under high pump powers leads to the decease of Raman gain coefficient [43], which is also a reason for drop of the slope efficiency. The average output power was 135.4 mW and the optical-to-optical efficiency was 5.2% at $P_{abs} = 2.64$ W. The output power of the Yb:YAG/Cr⁴⁺:YAG/YVO₄ PQSRML can be further scaled up by utilizing longer Raman crystal and optimizing the coating parameters of both the laser crystal and Raman crystal. Another alternative approach to enhance performance of PQSRML is applying thermal bonding technique to decline the intracavity loss with less number of optical surfaces in the future. The output Raman laser beam profiles were monitored and measured at different absorbed pump powers. The transverse laser profiles are nearly TEM_{00} mode and the measured beam quality factor M^2 is less than 1.3 which shows a near-diffraction-limited beam quality achieved in the Yb:YAG/Cr⁴⁺:YAG/YVO₄ PQSRML. The intracavity laser mode size was estimated to be 80 μ m in diameter by measuring the output beam diameter near the output coupler.

Because the Raman laser in the Yb:YAG/Cr⁴⁺:YAG/YVO₄ PQSRML is converted from the intracavity fundamental laser through SRS nonlinear process, the output pulse trains of the Raman laser is synchronized with that of the fundamental laser. Therefore, the repetition rate is identical for the Raman laser and the fundamental laser when P_{abs} is above the Raman laser threshold. Fig. 4 depicts the typical pulse trains in the Yb:YAG/Cr⁴⁺:YAG/YVO₄ PQSRML at P_{abs} = 2.2 W and 2.64 W, respectively. The periodical pulsation was observed in the pulse trains at different P_{abs}. The periodical pulsation in the Yb:YAG/Cr⁴⁺:YAG/YVO₄ PQSRML is caused by the multi-longitudinal mode oscillation of the fundamental



Fig. 5. Typical fundamental laser pulse profile and Raman laser pulse profile in the Yb:YAG/Cr⁴⁺:YAG/YVO₄ PQSRML at $P_{abs} = 2.64$ W.

laser around 1030 nm and 1050 nm. The multi-longitudinal mode oscillation induced periodical pulsation has been observed in the Cr⁴⁺:YAG passively Q-switched Yb:YAG microchip laser [44]. The longitudinal modes induced periodical pulsation in passively Q-switched Yb:YAG microchip laser can be alleviated by adjusting the intensities and mode separation among the longitudinal modes through tilting etalon effect. The separation and intensities of the longitudinal modes can be controlled by adjusting the thickness of Yb:YAG, Cr⁴⁺:YAG and YVO₄ crystals in Yb:YAG/Cr⁴⁺:YAG/YVO₄ PQSRML. Therefore, the stable pulse trains with relative small amplitude fluctuation is expected for potential applications in the Yb:YAG/Cr⁴⁺:YAG/YVO₄ PQSRML.

The output pulse profiles of the fundamental laser and Raman laser were measured by separating the fundamental laser and Raman laser at different absorbed pump powers. The measured pulse profiles of the residual fundamental laser and the Raman laser at $P_{abs} = 2.64$ W are shown in Fig. 5. The Raman laser pulse profile is totally different from the residual fundamental laser pulse profile. The Raman laser pulse profile is asymmetrical with sharp rising edge and wide pulse falling edge, while the fundamental laser pulse profile is also asymmetrical with a smooth rising edge and a rapid falling edge. The sharp rising edge in the Raman laser pulse was due to pulse energy extraction from the intracavity fundamental laser pulse and the pulse compression effect of SRS process. Formation of the Raman laser pulse starts from the intracavity fundamental laser pulse rising edge with intensity higher than the Raman laser threshold. And then the Raman laser pulse grows rapidly with rapid depleting fundamental laser field. Therefore, the sharp rising edge in the Raman laser is formed. The measured residual fundamental laser pulse is the remained intracavity fundamental pulse after the extraction of the Raman laser pulse. Thus, the residual fundamental laser pulse exhibits smooth rising edge and sharp fall edge. The Raman laser pulse duration was measured to be 440 ps while the fundamental laser pulse duration was measured to be 943 ps at $P_{abs} = 2.64$ W. Although the measured Raman laser pulse profile is the overlapping of the Raman laser



Fig. 6. (a) Repetition rate, (b) pulse width, (c) pulse energy and (d) peak power of the Yb:YAG/Cr⁴⁺:YAG/YVO₄ PQSRML vs. the absorbed pump power.

pulses at different wavelengths of 1079.22, 1134.66, 1157.06 and 1262.2 nm (as shown in Fig. 2), the contribution of the 1079.22 nm and 1157.06 nm Raman laser can be neglected. Therefore, the measured Raman laser pulse is the overlap of the pulses of 1134.66 nm and 1262.2 nm, the 1262.2 nm Raman laser pulse is the dominant component and is stronger than that of 1134.66 nm owing to the efficient conversion of the first-order Stokes laser to the second-order Stoke laser. Thus, the measured Raman laser pulse profile can be roughly treated as the pulse profile of 1262.2 nm second-order Stokes laser pulse. The theoretical estimation of the Raman laser pulse was done by applying the theoretical formula [45] taking into account the losses of first-order and second-order Stokes laser in Yb:YAG/Cr⁴⁺:YAG/YVO₄ PQSRML. The theoretically calculated pulse duration is 400 ps, which is in good agreement with the measured Raman laser pulse duration. The pulse duration of Raman laser was dramatically compressed compared to the residual fundamental laser pulse duration. The fundamental laser pulse energy and the Raman laser pulse energy were measured to be 2.63 μ J and 4.04 μ J, respectively. The corresponding peak power of the fundamental laser and Raman laser were 2.8 kW and 9.2 kW, respectively. This peak power is higher than those of the reported self-Raman microchip lasers based on Yb^{3+} doped materials [35], [37], [39], [40], which is benefiting from the good thermal management with separated laser medium and Raman medium configuration.

Fig. 6 shows the repetition rate, pulse width, pulse energy, and peak power of the Yb:YAG/Cr⁴⁺:YAG/YVO₄ PQSRML varying with the absorbed pump power. The repetition rate of the Yb:YAG/Cr⁴⁺:YAG/YVO₄ PQSRML increases linearly with P_{abs}. The highest repetition rate is 20.3 kHz at P_{abs} = 2.64 W. The fundamental laser pulse duration slightly increases from 900 ps to 943 ps with the increase of P_{abs} from 0.98 W to 2.64 W. While the Raman laser pulse duration decreases from 512 ps to 440 ps as P_{abs} increases from 0.98 W to 2.64 W. The slight broadening of the fundamental laser pulse duration is due to the severe thermal loading under high pump power. For Cr⁴⁺:YAG crystal, the initial transmission tends to slightly increase with the rising of temperature [46], which leads to the



Fig. 7. Raman laser conversion process in Yb:YAG/Cr⁴⁺:YAG/YVO₄ PQS-RML with 1030 nm and 1050 nm dual-wavelength fundamental laser oscillation.

enlargement of the pulse duration. The fundamental laser pulse energy decreases from 7 μ J to 2.6 μ J and the Raman laser pulse energy increases from 0.7 μ J to 4.04 μ J when P_{abs} increases from 0.98 W to 2.64 W. The peak power of the fundamental laser decreases from 7.76 kW to 2.8 kW, and the peak power of the Raman laser raises from 1.35 kW to 9.2 kW when P_{abs} is increased from 0.98 W to 2.64 W.

IV. DISCUSSIONS

The multiple wavelengths Raman laser conversion process in Yb:YAG/Cr⁴⁺:YAG/YVO₄ PQSRML under 1030 and 1050 nm dual-wavelength fundamental laser oscillation is illustrated in Fig. 7 by taking an typical example of the laser emitting spectrum at $P_{abs} = 2.64 \text{ W}$. 1030 and 1050 nm dual-wavelength fundamental lasers in Yb:YAG/Cr4+:YAG/YVO4 PQSRML make the multi-wavelength Raman laser oscillation more colorful. The Raman laser at 1134 nm is the first-order Stokes laser converted from 1030 nm fundamental laser with Raman shift of 890 cm⁻¹ for c-cut YVO₄ crystal. The Raman laser at 1262 nm is the second-order Stokes laser converted from the first-order Stokes laser at 1134 nm with Raman shift of 890 cm⁻¹. The first-order Stokes lasers at 1079 nm and 1156 nm are generated with the Raman shift 259 cm^{-1} and 890 cm^{-1} from 1050 nm fundamental laser. The intensities of the multi-wavelength Stokes lasers at 1079 nm, 1134 nm, 1156 nm and 1262 nm are determined by the absorbed pump power and reflection coatings on the YVO₄ crystal.

The multi-wavelength Raman laser oscillation in the Yb:YAG/Cr⁴⁺:YAG/YVO₄ PQSRML is governed by the 1030 nm and 1050 nm dual fundamental laser oscillation of Yb:YAG crystal and the multiple Raman frequency shift lines of YVO₄ crystal. When the single-pass gain for the Raman laser is high enough to overcome the losses, the first-order Stokes laser starts to oscillate. The SRS threshold can be described as [47]:

$$R_{in}R_{out}\left(1-L\right)\exp\left(2g_RI_{th}l_R\right) \ge 1\tag{1}$$

where I_{th} is the SRS threshold intensity for the fundamental laser, g_R is the steady-state Raman gain coefficient, l_R is the length of Raman crystal, L is the resonator loss for the Stokes laser, R_{in} is the reflectivity of the rear cavity mirror, and R_{out} is the reflectivity of the OC at the Raman laser wavelength. According to the steady-state Raman gain coefficients of 890 and 816 cm⁻¹ of YVO₄ crystal for 1064 nm fundamental laser [19], g_R for 890 cm⁻¹ is approximately 1.7 times of that for 816 cm⁻¹. The SRS threshold intensities of the first-order Stokes laser at 1123 nm was calculated to be 1.7 times of that at 1134 nm before the second-order Stokes laser at 1260 nm was generated. The threshold intensity for 1134 nm was lower than that for 1123 nm, so that the first-order Stokes laser at 1134 nm began to oscillate firstly. When the intracavity intensity of the Raman laser at 1134 nm was increased sufficient to overcome the oscillating threshold of the second-order Stokes laser at 1260 nm, the second-order Stokes laser started to oscillate. The conversion from 1134 nm Raman laser to second-order Stokes laser by cascaded SRS effect can be regard as output coupling loss for the first-order Stokes laser. Therefore, the generation of the second-order Stokes laser increases the intracavity single-pass transmission losses of the 1134 nm Raman laser. As the reflection of the YVO₄ crystal at 1134 nm and 1123 nm is nearly the same, the increased loss for 1134 nm Raman laser owing to conversion to 1260 nm second-order Stokes laser makes 1123 nm Raman laser with 816 cm⁻¹ Raman shift possible to oscillate. When the intracavity intensity of the 1030 nm fundamental laser was sufficient to overcome the lasing threshold of 1123 nm Raman laser with the Raman vibrational mode line of 816 cm^{-1} , the dual-wavelength Raman laser at 1134 nm and 1123 nm was generated. Meanwhile, two Raman vibrational mode lines compete with each other because they consume the same fundamental laser field. The dual-wavelength fundamental laser operation were mainly due to the gain and loss balance at 1030 nm and 1050 nm induced by aggravated self-absorption at 1030 nm induced by the temperature rising with the increased pump power [32]. Moreover, the nonlinear conversion process of SRS can be treated as a consumption process for the fundamental laser field at the primary emission line of 1030 nm, resulting in the increase of the transmission losses for 1030 nm fundamental laser, which also contributed to the dual-wavelength fundamental laser operation.

The red-shift of the laser wavelength with the pump power in the Yb:YAG/Cr⁴⁺:YAG/YVO₄ PQSRML is attributed to the local temperature rise inside Yb:YAG and YVO₄ crystal with increase in the pump power. Temperature rising inside the Yb:YAG crystal and YVO₄ crystal has two effects on the laser emitting wavelengths. The thermal induced expansion of YVO₄ crystal lattice makes the temperature dependent Raman frequency shift with a ratio of -0.023 cm⁻¹/K [43]. While the temperature dependent emission peak of Yb:YAG crystal red-shift with a ratio of 0.008 nm/K [32]. Therefore, the wavelength shift of the second-order Stokes laser in the Yb:YAG/Cr⁴⁺:YAG/YVO₄ PQSRML is calculated to be 2.1 nm when the absorbed pump power is increased from 1.7 W to 2.7 W. The calculated wavelength shift with the pump power is in good agreement with the experimental data

TABLE I Comparison of Output Characteristics of Cr^{4+} :YAG Passively Q-Switched Yb³⁺ Doped Crystals Miniature Raman Lasers

Crystal	λ_S , nm	P _S , mW	$E_s, \mu J$	P _{peak} , kW	$\tau_{\rm S},$ ns	Ref.
Yb:YAG/ YVO ₄	1079–1260	82	4.04	9.2	0.44	This work
Yb:KLuW	1151	119	3	1.5	2	[39]
Yb:YVO ₄	1119.5	89	3.6	0.59	6	[40]
Yb:KGW	1145	110	8.2	11	0.7	[36]
Yb:KGW	1139	7	0.4	0.02	20	[35]

Notes: λ_S –Stokes laser emission wavelength; P_S – maximum average output power of Stokes laser; E_s – maximum pulse energy of Stokes laser; P_{peak} – maximum peak power of Stokes laser; τ_S – shortest pulse width of Stokes laser.

(1.72 nm red-shift of the second-order Stokes laser as shown in Fig. 2).

The laser emission results (as shown in Fig. 2) indicate that the efficiency of cascaded SRS converting process is enhanced with Pabs. The emerging of 1079 nm, 1123 nm, and 1156 nm can be regarded as parasitic losses and should be avoided to boost the conversion efficiency in the process of cascaded Stokes generation. Therefore, it needs complicated design of mirror coatings or inserting frequency selector in order to increase the oscillation threshold of unwanted Stokes lines. Based on the present microchip laser cavity design, the weak Stokes lines were nearly all suppressed under high pump power. And experimental laser emitting spectral results show that the multiple Stokes lines oscillation has less impact on the generation of second-order Stokes laser in the experiment. Moreover, the multiple Stokes laser oscillation has some special applications in many fields such as terahertz wave generation and visible laser generation with frequency doubling technique. Based on the dual-wavelength oscillation with narrow separation at 1030 nm/1050 nm, 1123 nm/1134 nm, and 1134 nm/1156 nm, the corresponding THz wave frequency of 5.55 THz, 2.59 THz and 5.03 THz can be expected. Combining with SHG (second harmonic generation) or SFG (sum-frequency generation), broadband visible lines ranging from green to red region (515 nm-630 nm) can be produced. These visible radiations have some significant applications in biomedicine, laser display, and optical sensing.

Table I summarizes output laser characteristics of this work and some typical passively Q-switched intracavity miniature Raman lasers with Yb³⁺ ions doped laser crystals as gain media. Besides the shortest pulse width of 440 ps has been achieved in Yb:YAG/Cr⁴⁺:YAG/YVO₄ PQSRML, multiple wavelengths of fundamental laser, first-order Stokes laser and second-order Stokes laser have been obtained. The multiwavelength, sub-nanosecond laser pulses generated in the Yb:YAG/Cr⁴⁺:YAG/YVO₄ PQSRML offer a potential laser source for flexible applications comparing to those reported results. The efficient generation of second-order Stokes laser at 1260 nm (about 60% efficiency from the first-order Stokes laser to second-order Stokes laser) under current laser design shows that an effective method for developing efficient cascaded SRS lasers by optimizing the laser components. The output power of the Yb:YAG/Cr⁴⁺:YAG/YVO₄ PQSRML can be further scaled up by utilizing longer Raman crystal and optimizing the coating parameters of both the laser crystal and Raman crystal. Moreover, pump power dependent multi-wavelength laser oscillation in the Yb:YAG/Cr⁴⁺:YAG/YVO₄ PQSRML provides potential possibilities to develop simultaneous multiple or single specific wavelength laser by optimizing the length and coating parameters of crystals to control the gain and loss for different laser radiations in the PQSRML. Note that the available coating parameters of both the laser crystal and Raman crystal were not optimal for the cascaded SRS generation process. Part of backward-propagating second-order Stokes laser leaked through the input surface of Yb:YAG crystal because of the input surface of Yb:YAG crystal was only HR coated at 1030-1100 nm or were absorbed by Cr⁴⁺:YAG crystal. So the performance of the 1262 nm Raman laser generated in the Yb:YAG/Cr⁴⁺:YAG/YVO₄ PQSRML could be enhanced with longer length of Raman crystal and higher reflection coating at the wavelengths for both fundamental laser and first-order Stokes laser. Otherwise, high transmission at the wavelength of the second-order Stokes laser as well as appropriate partial transmission at the first-order Stokes laser should be benefit for the efficient performance of the first-order Stokes laser by fully

V. CONCLUSION

suppressing the oscillation of the second-order Stokes laser.

In conclusion, multi-wavelength laser at 1–1.26 μm with sub-nanosecond pulse duration and high repetition rate from a laser-diode end-pumped Yb:YAG/Cr⁴⁺:YAG/YVO₄ PQSRML has been demonstrated for the first time to our best knowledge. Simultaneous multi-wavelength Raman lasers at 1123, 1134, and 1260 nm converted from 1030 nm fundamental laser have been achieved under Pabs between 1.55 W and 2.17 W in the cascaded SRS generation process. By simultaneously utilizing 1030 nm and 1050 nm fundamental lasers, multi-wavelength Stokes lasers at 1079 nm, 1134 nm, 1156 nm, and 1262 nm have been obtained at $P_{abs} > 2.17$ W. The maximum average output power was measured to be 135.4 mW at $P_{abs} = 2.64$ W. The Raman laser pulse duration of 440 ps, peak power of 9.2 kW, and the repetition rate of 20.3 kHz were achieved at $P_{abs} =$ 2.64 W. The high peak power, dual-wavelength laser radiation at 1030 nm/1050 nm, 1123 nm/1134 nm, and 1134 nm/1156 nm paves a new way for developing miniature laser source for laser spectroscopy, pumping Ho³⁺-doped fiber lasers, generating yellow laser by second harmonic generation and terahertz generation. The high peak power Raman laser around 1260 nm could be a potential laser source in drug-free photodynamic therapy and generating red laser.

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